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Changling Fang^a, Xiaoyi Lou^a, Ying Huang^a, Min Feng^a, Zhaohui Wang^{a,b,*}, Jianshe
Liu^a

^a *State Environmental Protection Engineering Center for Pollution Treatment and
Control in Textile Industry, College of Environmental Science and Engineering,
Donghua University, Shanghai, 201620, China*

^b *International Centre for Balanced Land Use (ICBLU), The University of Newcastle,
Callaghan, NSW 2308, Australia*

Tel: +86-21-67792557; Fax: +86-21-67792522

E-mail: zhaohuiwang@dhu.edu.cn (Z. Wang)

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